Examiner-Initiated Interview Summary	Application No.	Applicant(s)
	09/940,855	NAMBA, KAZUYOSHI
	Examiner	Art Unit
	Mark Spisich	1744
All Participants:	Status of Application	
(1) <u>Mark Spisich</u> .	(3)	
(2) <u>Michael Makuch (Appl Rep)</u> .	(4)	
Date of Interview: 8 November 2004	Time:	
Type of Interview:  ☐ Telephonic ☐ Video Conference ☐ Personal (Copy given to: ☐ Applicant ☐ Applica  Exhibit Shown or Demonstrated: ☐ Yes ☐ No If Yes, provide a brief description:	int's representative)	
Part I.		
Rejection(s) discussed: 102(e) based on Nishimura et al (USP 6,286,525)		
Claims discussed: 4 and 7		
Prior art documents discussed:  Nishimura et al (USP 6,286,525)		
Part II.		Y
SUBSTANCE OF INTERVIEW DESCRIBING THE GENER See Continuation Sheet.	AL NATURE OF WHAT W	/AS DISCUSSED:
Part III.		
<ul> <li>☑ It is not necessary for applicant to provide a separate redirectly resulted in the allowance of the application. The of the interview in the Notice of Allowability.</li> <li>☑ It is not necessary for applicant to provide a separate reddid not result in resolution of all issues. A brief summary</li> </ul>	examiner will provide a w	ritten summary of the substance
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mare Spine		
	oplicant's Representative	Signature – if appropriate)

Continuation of Substance of Interview including description of the general nature of what was discussed: Applicant had amended claims 4 and 7 by reciting that the first and second scrub heads each passed through the rotation center of the wafer and noved toward the periphery thereof. Although the prior art ('525) fails to disclose the scrub heads doing this during cleaning of the wafer, they do each pass through the center as they move FROM the cleaning position TO the rest position (see fig 8B). The examiner proposed amending claims 4 and 7 to clarify that each of the scrub heads passes through the rotation center while they are cleaning the wafer.